

## PRESERVING MICROMETRE TOLERANCES THROUGH THE ASSEMBLY PROCESS OF AN X-BAND ACCELERATING STRUCTURE



On both structures there is a reduction of the frequency devia-

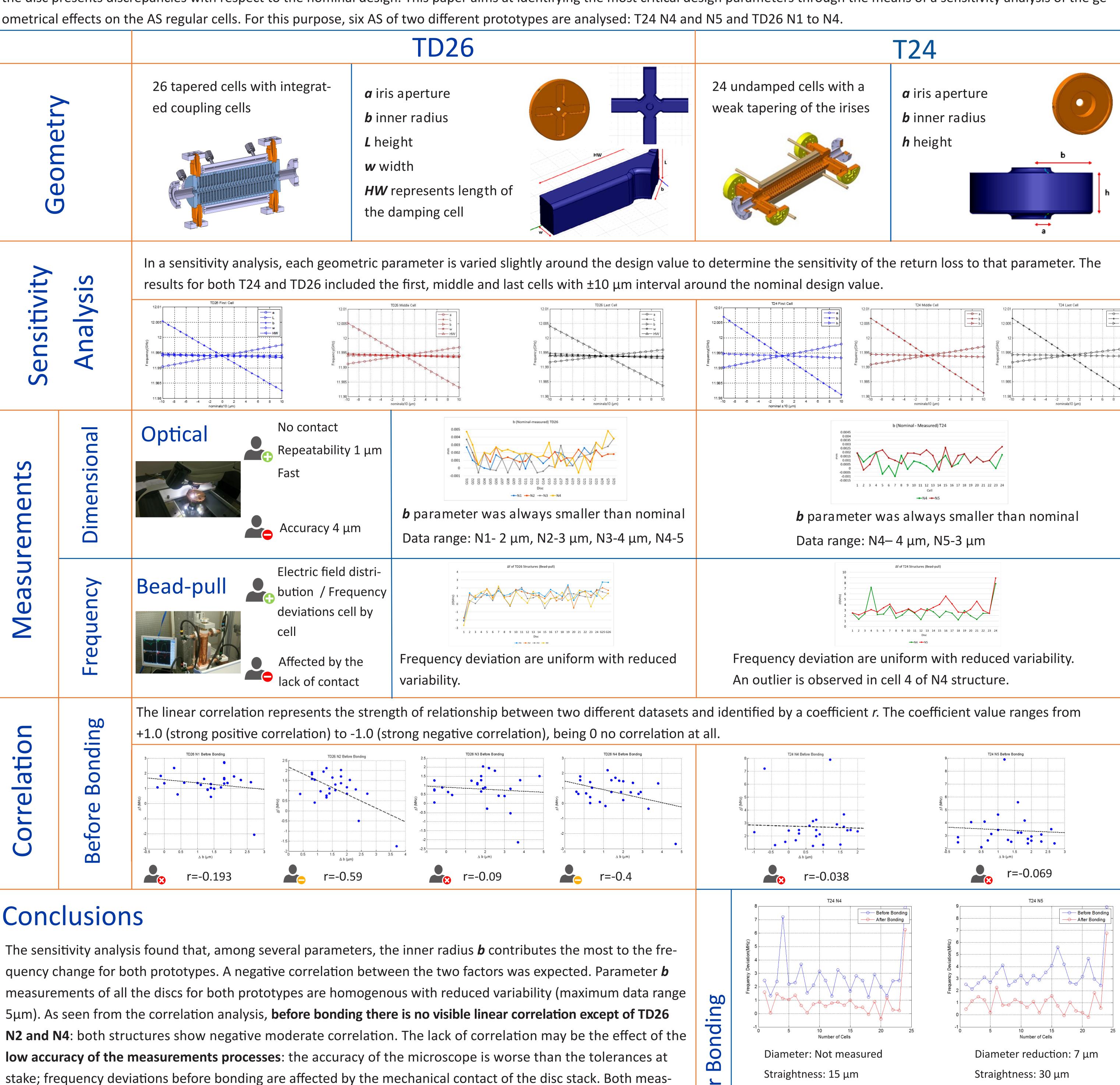
tion. It is then clear that there has been a change on the RF ge-

ometry.

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## Introduction

LIC baseline accelerating structure stack is composed by a variable quantity of discs of the prototype being produced. The cavity formed by the disc represents the RF zone. The geometry of the disc depends on different parameters and each of these parameters contributes differently to satisfy the RF design. Sub-micrometre tolerances are needed to reach the accelerating gradient goal of 100 MV/m if no tuning is applied and if no temperature correction is allowed to the structure. However, the normal variability of the manufacturing processes makes that the disc presents discrepancies with respect to the nominal design. This paper aims at identifying the most critical design parameters through the means of a sensitivity analysis of the geometrical effects on the AS regular cells. For this purpose, six AS of two different prototypes are analysed: T24 N4 and N5 and TD26 N1 to N4.



urement processes have to be greatly improved in order to get reliable data. The b parameter measurement is

now an important requirement for suppliers. Another possibility is that the data follows another type of correla-

Finally, there is evidence of a **geometry change in the cells after bonding** since there is a reduction of frequency

deviation. Nevertheless, it is not possible to numerically assess the change due to the inaccessibility of the RF cavi-

tion or the combined effect of more than one parameter.

ty. Other possible causes need to be further investigated.